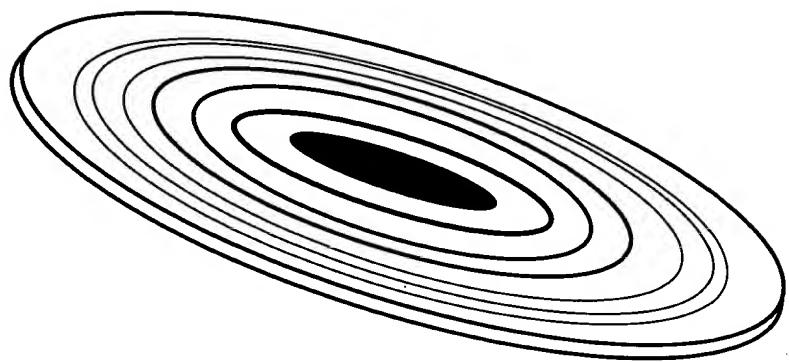


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FIG.1



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FIG.2A

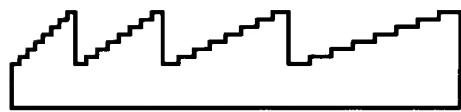


FIG.2B



FIG.3

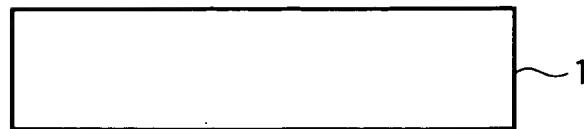


FIG.4

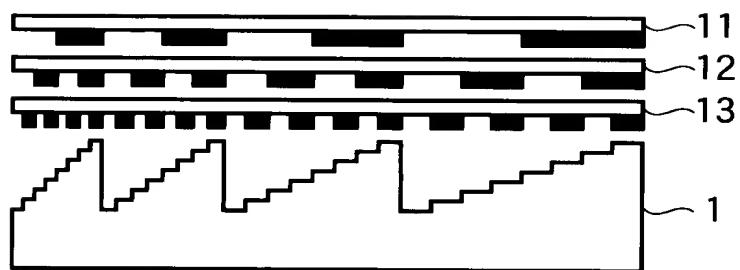


FIG.5

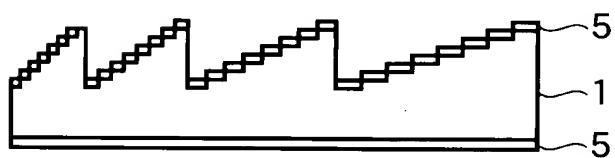


FIG.6

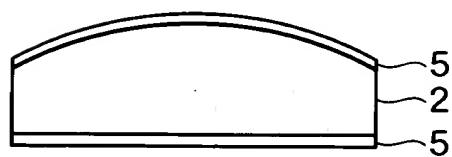
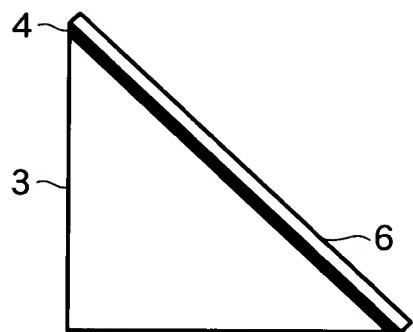


FIG. 7



The diagram illustrates a lithography system. On the left, a large bracket labeled "FIG.8" groups four components: "ILLUMINATION SYSTEM" (represented by a rectangle), "MASK" (represented by a horizontal bar with a series of vertical slits), "PROJECTION SYSTEM" (represented by an irregular pentagon), and "WAFER" (represented by a horizontal bar). The "MASK" and "WAFER" labels have leader lines pointing to their respective symbols.